

Photonic Wire Bonding and 3D Nanoprinting in Photonic Integration – from Lab Demonstrations to Production

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Abstract We give an overview of our research towards exploiting direct-write 3D laser lithography as a tool for advanced photonic integration. The technique offers new perspectives for a wide variety of applications, ranging from photonic wire bonding and multi-chip integration of high-speed communication engines to facet-attached beam-shaping elements and highly efficient coupling in astrophotonic systems. We are currently working on transferring the concept from laboratory demonstrations to industrial manufacturing.

Summary

Single-mode chip-to-chip and fiber-to-chip interfaces represent a key challenge in packaging and assembly of photonic integrated systems [1]. On the optical side, this challenge comprises two main aspects: First, on-chip waveguides frequently feature small mode-field diameters, in particular when high index-contrast silicon-photonic (SiP) or InP-based components are involved. Low-loss coupling hence requires highest positioning accuracy of optical components, which often relies on comparatively complex and expensive active alignment techniques. Second, optical interfaces have to cope with vastly different mode field profiles that need to be carefully adapted for efficient coupling.

In this presentation, we will give an overview of our research towards harnessing three-dimensional (3D) nanoprinting techniques to overcome the various challenges in photonic packaging and system assembly. We have demonstrated that direct-write two-photon lithography is perfectly suited for connecting photonic chips by 3D free-form single-mode waveguides, so-called photonic wire bonds [2] – [5]. This concept does not only allow to combine the distinct advantages of photonic integration platforms in high-performance hybrid multi-chip modules (MCM) [3] [4], but also greatly simplifies level-1 packaging and fiber-chip coupling of photonic integrated circuits (PIC) [5]. We demonstrated the viability of the concept by realizing multi-chip transmitter modules that combine silicon photonic modulators with InP-based laser-sources in highly integrated assemblies [6], [7]. Using the same lithography techniques, we have shown high-precision in-

situ printing of lenses to facets of photonic chips and optical fibers [8] – [10]. This approach does not only allow for low-loss coupling of PIC to free-space beams in a wide variety of optical assemblies, but also opens novel opportunities in other areas such as astrophotonics, where efficient coupling between free-space beams and optical fibers is essential [10]. Taking a long-term view, on-chip 3D freeform waveguides [11] might allow large-scale non-planar circuit topologies that are, e. g., at the heart of advanced optical switches. Based on substantial research efforts carried out over the previous years, we are currently working on transferring the technology to application in industrial production processes.

Acknowledgements

This work was supported by the BMBF joint projects PRIMA (grant 13N14630) and PHOIBOS (grant 13N12574), by the H2020 Photonic Packaging Pilot Line PIXAPP (# 731954), by the European Research Council (ERC Starting Grant ‘EnTeraPIC’, # 280145; ERC Consolidator Grant ‘TeraSHAPE’, # 773248), by the Deutsche Forschungsgemeinschaft in the framework of the collaborative research center “WavePhenomena” (CRC 1173), by the Alfried Krupp von Bohlen und Halbach Foundation, by the Karlsruhe Nano-Micro Facility (KNMF), by the Karlsruhe School of Optics and Photonics (KSOP), and by the Helmholtz International Research School for Teratronics (HIRST).

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